

Al

ALUMINIUM SPUTTERING TARGET

Aluminum sputtering target is widely used in the aerospace, automotive lighting, OLED, and optical industries. Some high purity aluminum targets are used in semiconductor chip, flat panel display, solar cell industries. Aluminium and its alloys are widely used for various applications including aircraft assemblies and engine parts.

Quick Facts

Product	:	Aluminium Sputtering Target
Stock No	:	NS6130-10-1054
CAS	:	7429-90-5
Backing Plate	:	(As per Customer requirement)

Additional Characteristics

Stock No.	Purity	Diameter	Thickness
NS6130-10-1054	99.99%	50.8 mm \pm 1mm	3 mm \pm 0.5mm

Technical Specification

Molecular Formula	Molecular Weight	Thermal Conductivity
Al	26.98g/mol	235W/m.K



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High Purity
SPUTTERING
TARGET